

B

BORON SPUTTERING TARGET

Boron is a chemical element with the symbol B and atomic number 5. Boron finds importance within nuclear reactors due to its neutron absorbing capabilities, boron steel being used as control rod material. Boron compounds are used for a number of applications including the manufacture of certain grades of glass and detergents.

Quick Facts

Product	:	Boron Sputtering Target
Stock No	:	NS6130-10-1130
CAS	:	7440-42-8
Backing Plate	:	(As per Customer requirement)

Additional Characteristics

Stock No.	Purity	Diameter	Thickness
NS6130-10-1130	99.99%	50.8 mm \pm 1mm	3 mm \pm 0.5mm

Technical Specification

Molecular Formula	Molecular Weight	Melting Point
B	10.811g/mol	2079 °C



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High Purity
SPUTTERING
TARGET